

UNITED STATES PATENT AND TRADEMARK OFFICE  
**CERTIFICATE OF CORRECTION**

PATENT NO. : 6,843,952 B1  
DATED : January 18, 2005  
INVENTOR(S) : Yokoyam, Chikafumi

Page 1 of 2

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

Column 1,

Line 34, delete "nib" and insert -- rib --, therefor.

Line 40, delete "(KOKA)" and insert -- (KOKAI) --, therefor.

Column 2,

Line 1, delete "a" before "exposing".

Line 32, delete "sill" and insert -- skill --, therefor.

Line 62-63, after "HEA" delete "hydroxyethyl acrylate)" and insert -- (hydroxyethyl acrylate) --, therefor.

Line 64, delete "dimetharylate" and insert -- dimethacrylate --, therefor.

Column 3,

Line 14, delete "γ-methacryloxypropylmethyldiethoxysilaneo" insert  
-- γ-methacryloxypropylmethyldiethoxysilaneo --, therefor.

Line 20, delete "15" before "network".

Line 30, delete "70%/" and insert -- 70% --, therefor.

Column 4,

Line 17, delete "oligorner" and insert -- oligomer --, therefor.

Line 21, delete "Chemnical" and insert -- Chemical --, therefor.

Lines 23-24, delete "photopolymerzation" and insert -- photopolymerization --, therefor.

Line 51, after "name of" delete "Lrgacure" and insert -- Irgacure --, therefor.

Line 63, delete "awavelength" and insert -- a wavelength --, therefor.

Line 63, delete "380 nm," and insert -- 380 nm --, therefor.

Column 5,

Line 31, delete "photopolymenzation" and insert -- photopolymerization --, therefor.

Line 40, delete "34," and insert -- 34. --, therefor.

Line 59, after "As a result" insert -- , --.

Column 6,

Line 8, delete "nib" and insert -- rib --. therefor.

Line 21, delete "EXAMPLE" and insert -- EXAMPLES --, therefor.